

Fig. 1

Fig. 2A

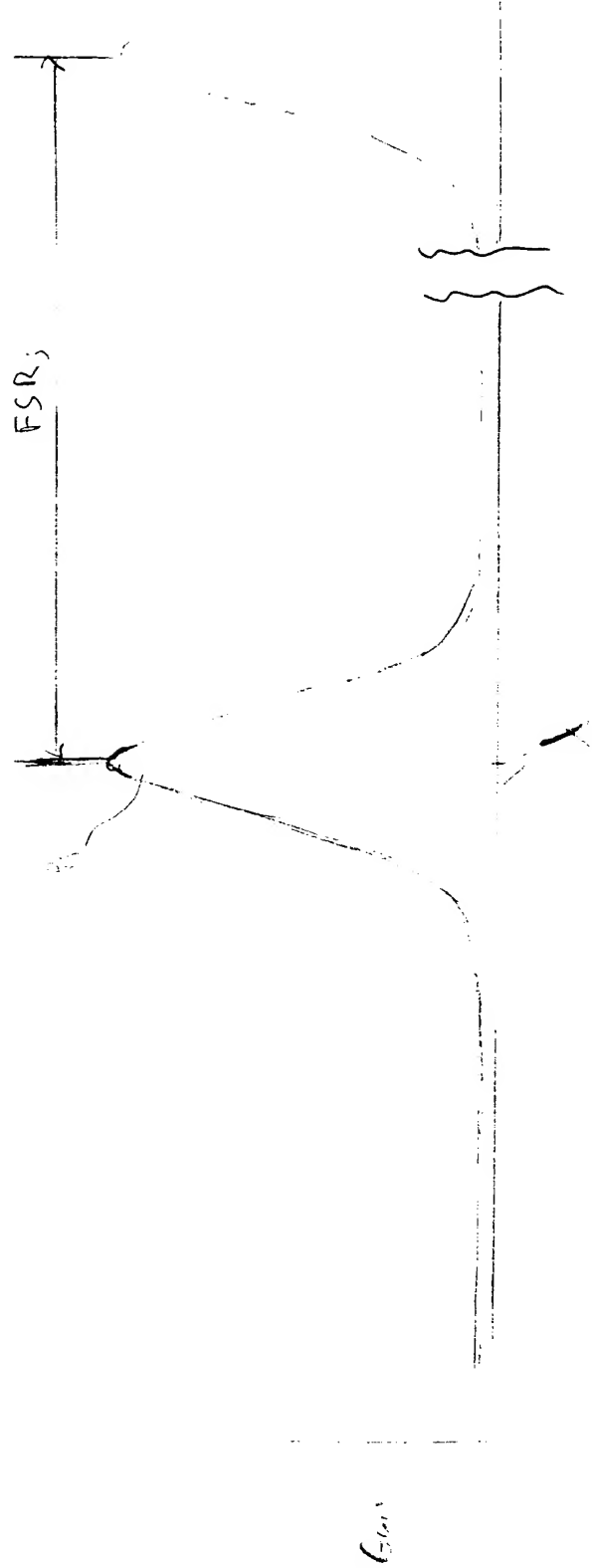
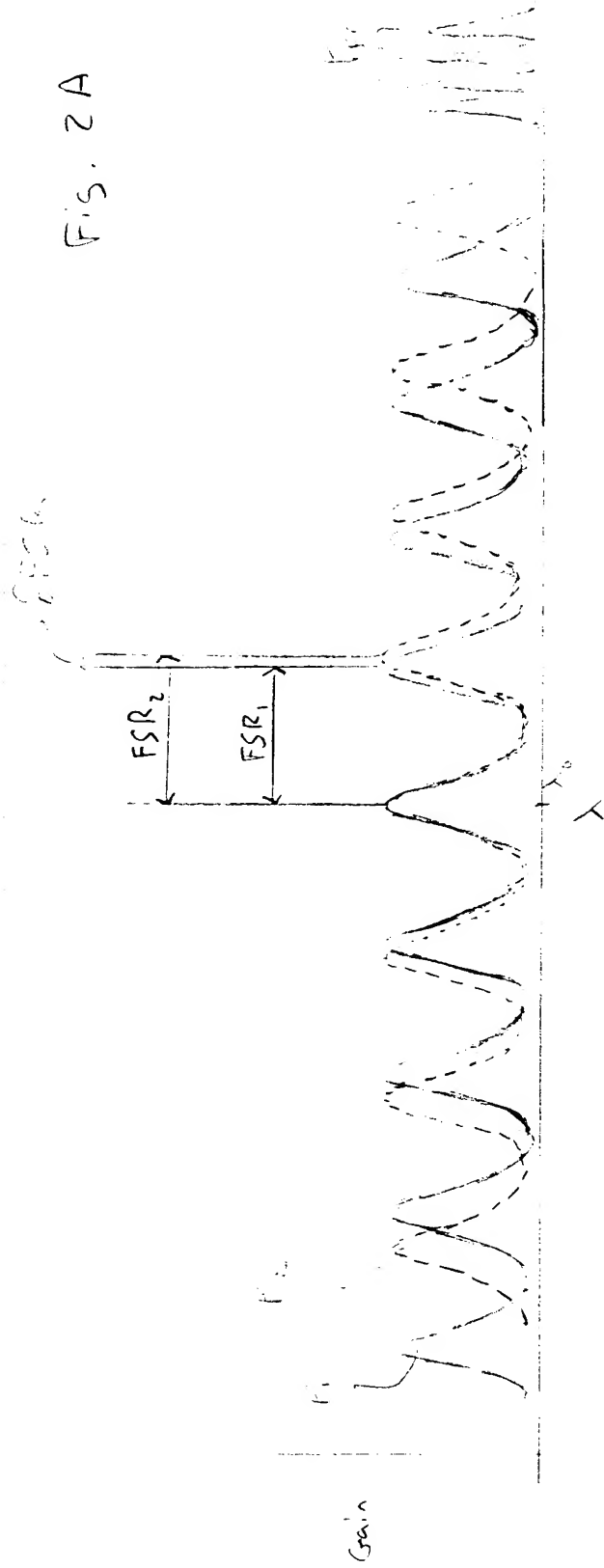
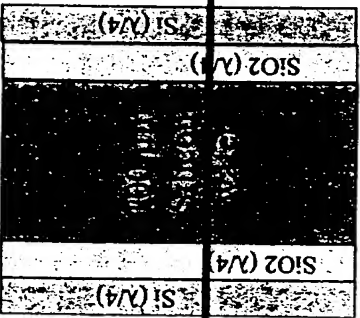
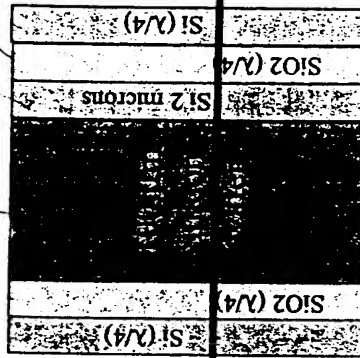


Fig. 2B



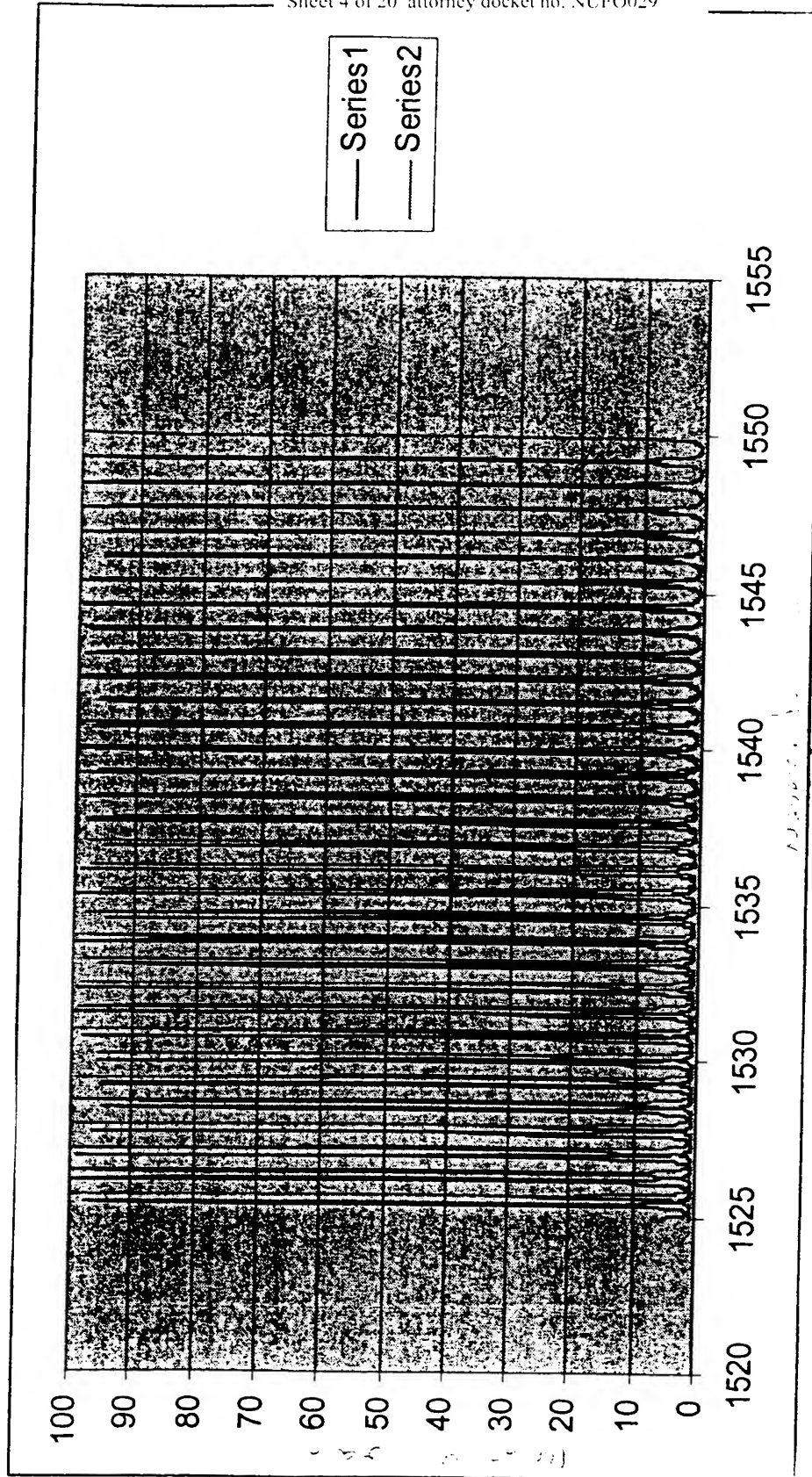


Fig. 4

Response of aligned 100 and 102 micron Silicon etalons with
SiO₂/Si mirror

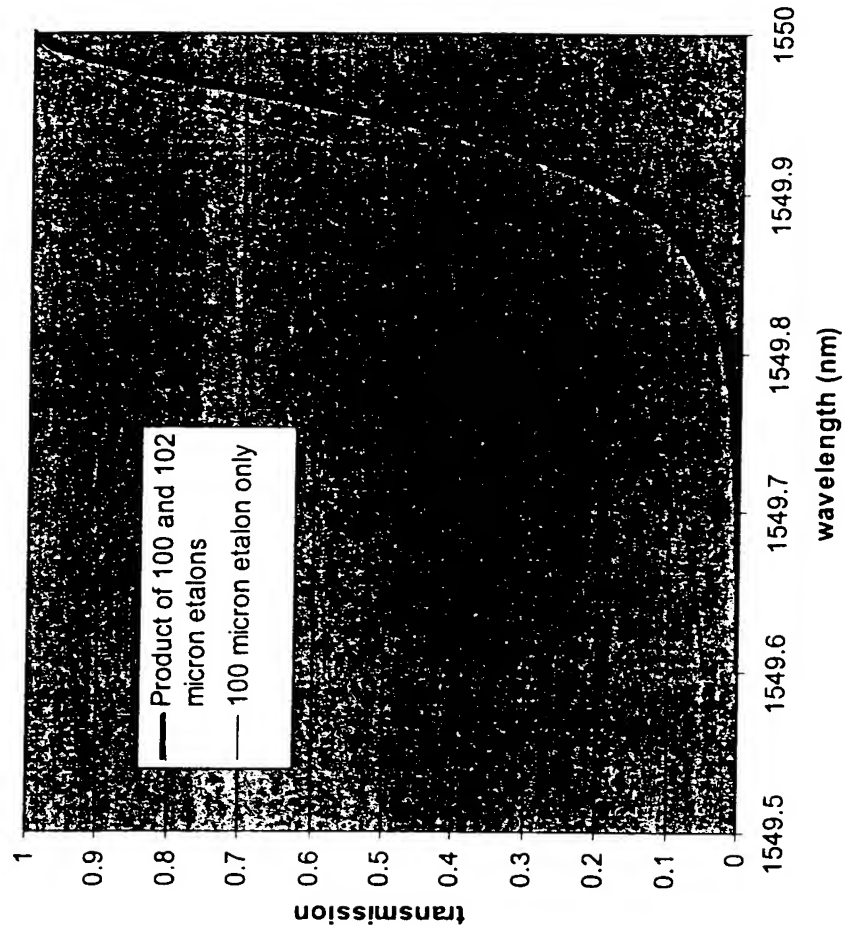


Fig 5

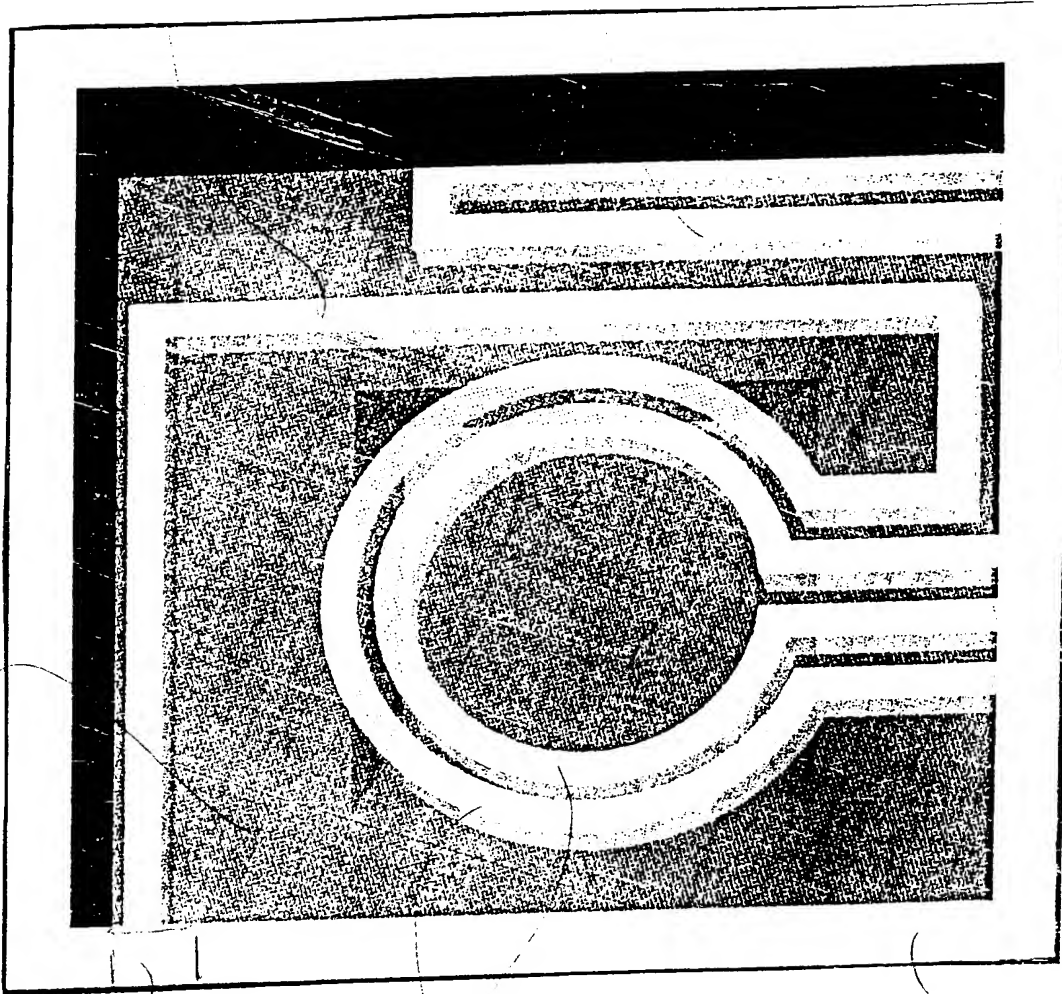


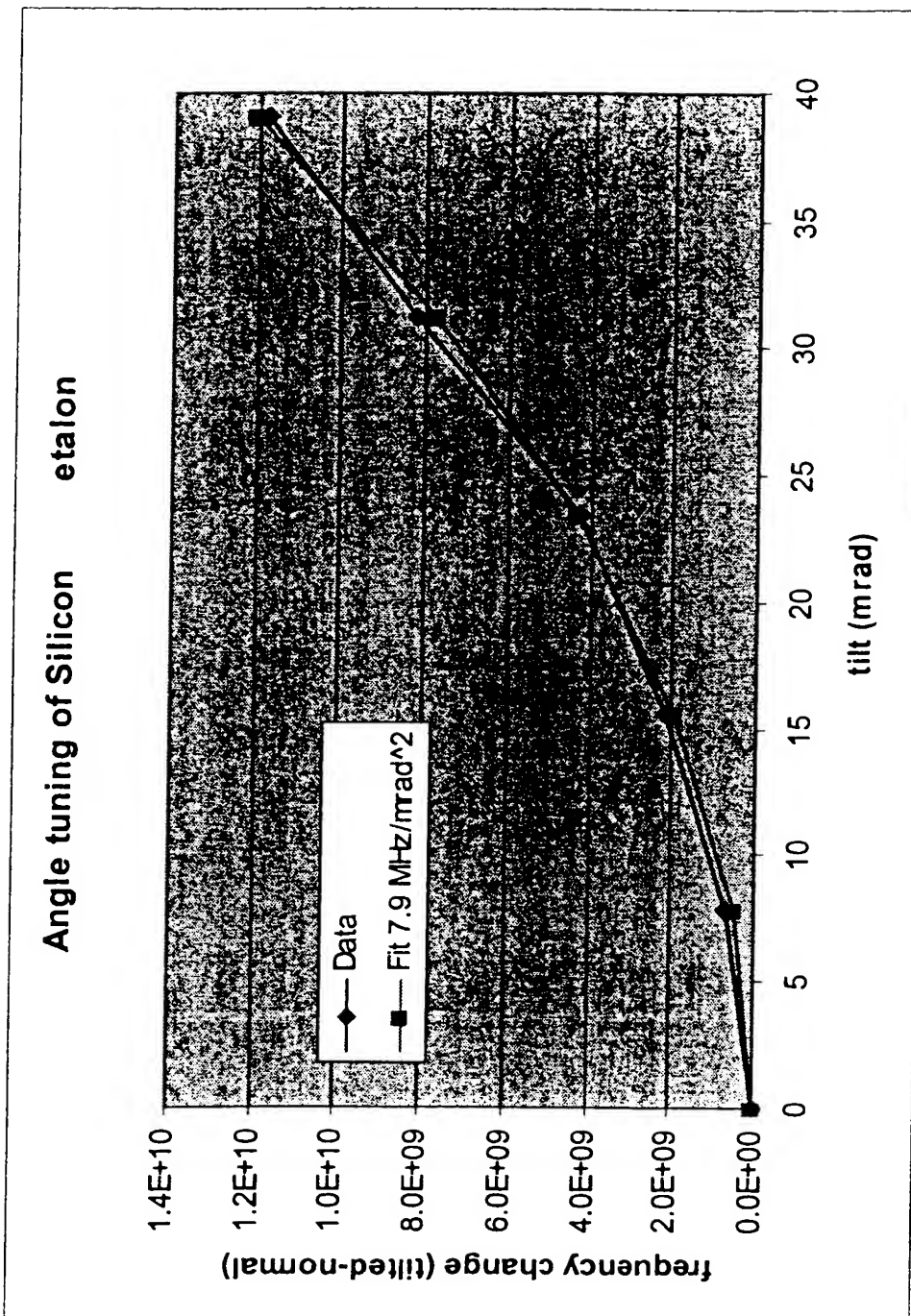
Fig. 6

95

76

24

11



0.3

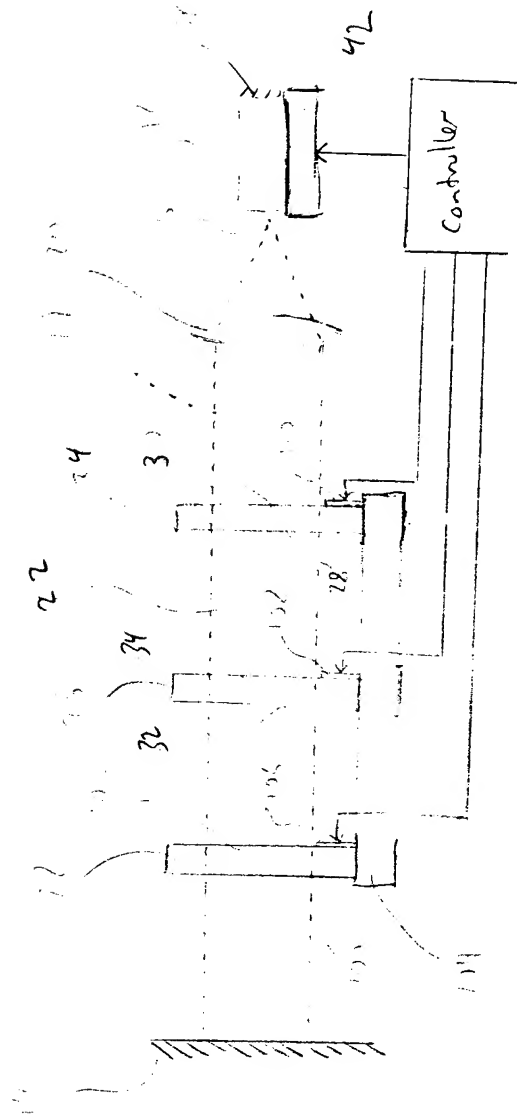


Fig. 5

U.S. Patent Application for:
TUNABLE EXTERNAL CAVITY LASER
Filing Date: March 15, 2002
Robert C. Hall (Reg. No. 39,209)
(650) 833-7772
Sheet 9 of 20 attorney docket no. NJF0029

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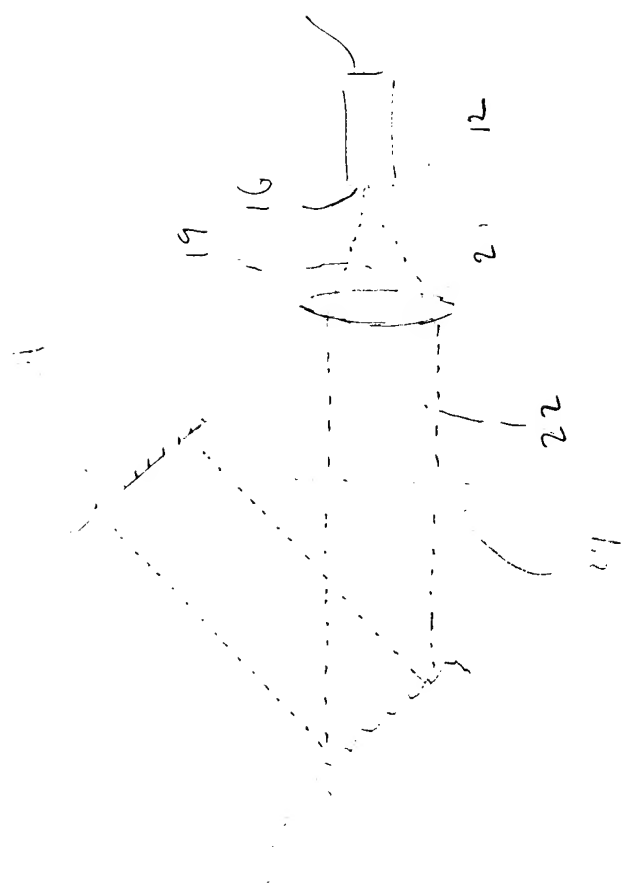


Fig. 10



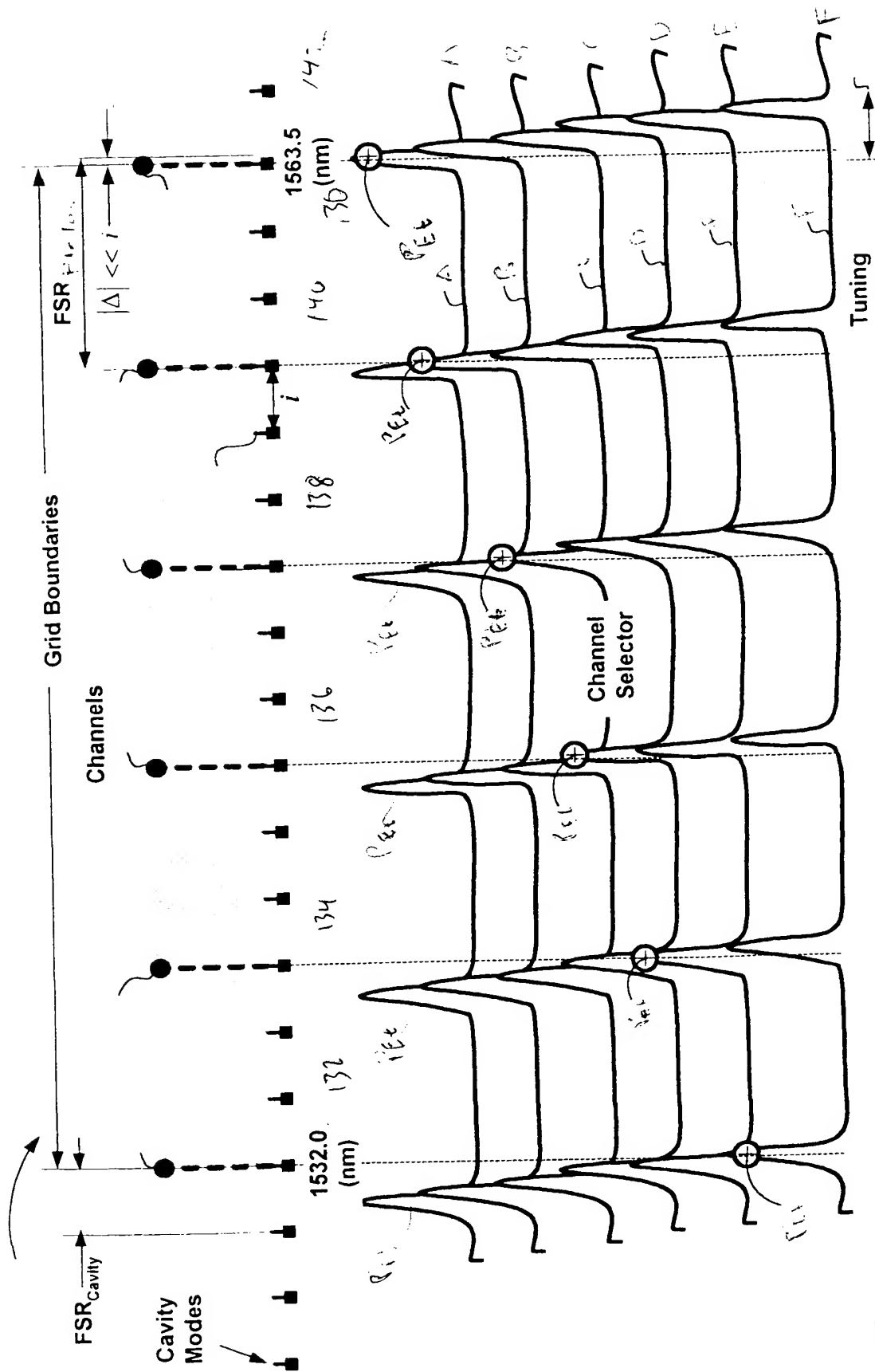


FIG. 1

U.S. Patent Application for: TUNABLE EXTERNAL CAVITY LASER

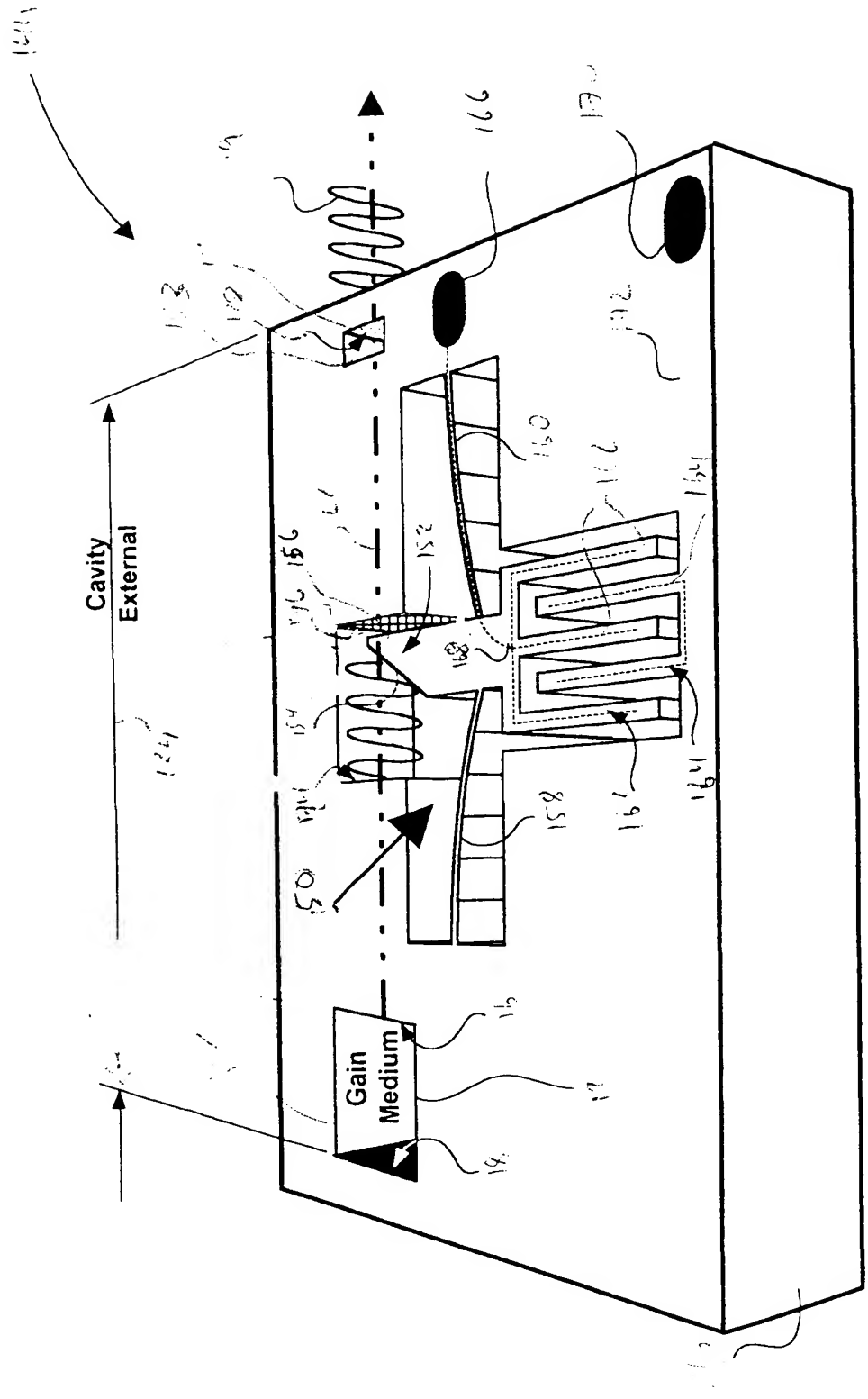


FIG.

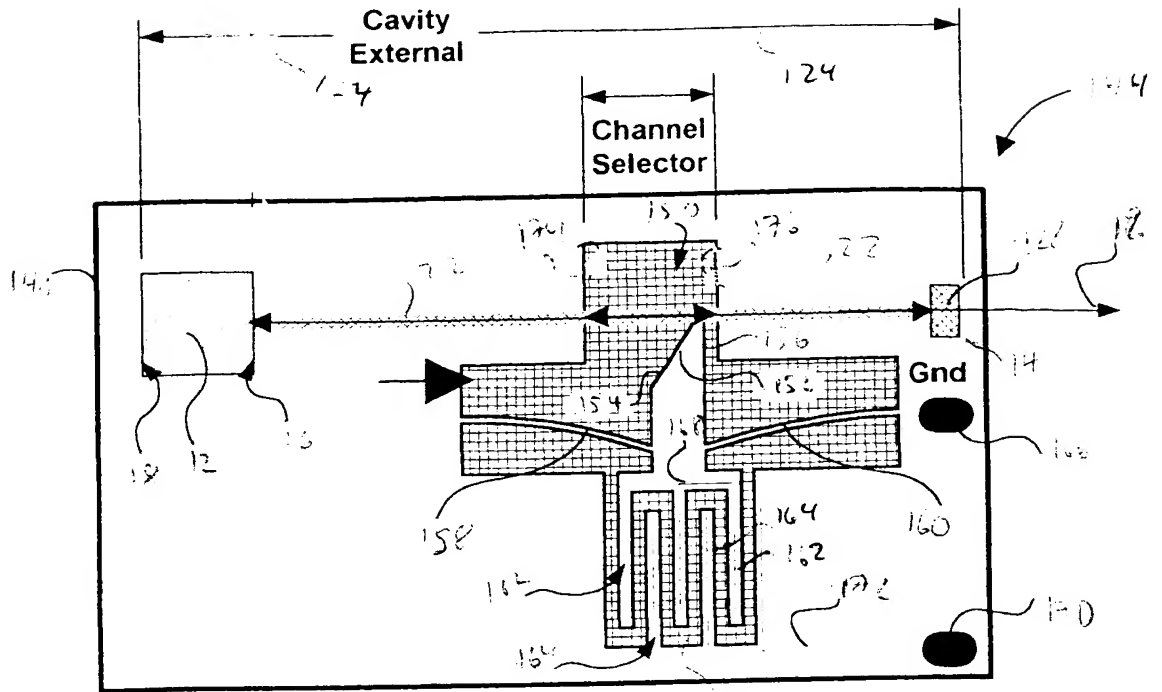


FIG. 12a

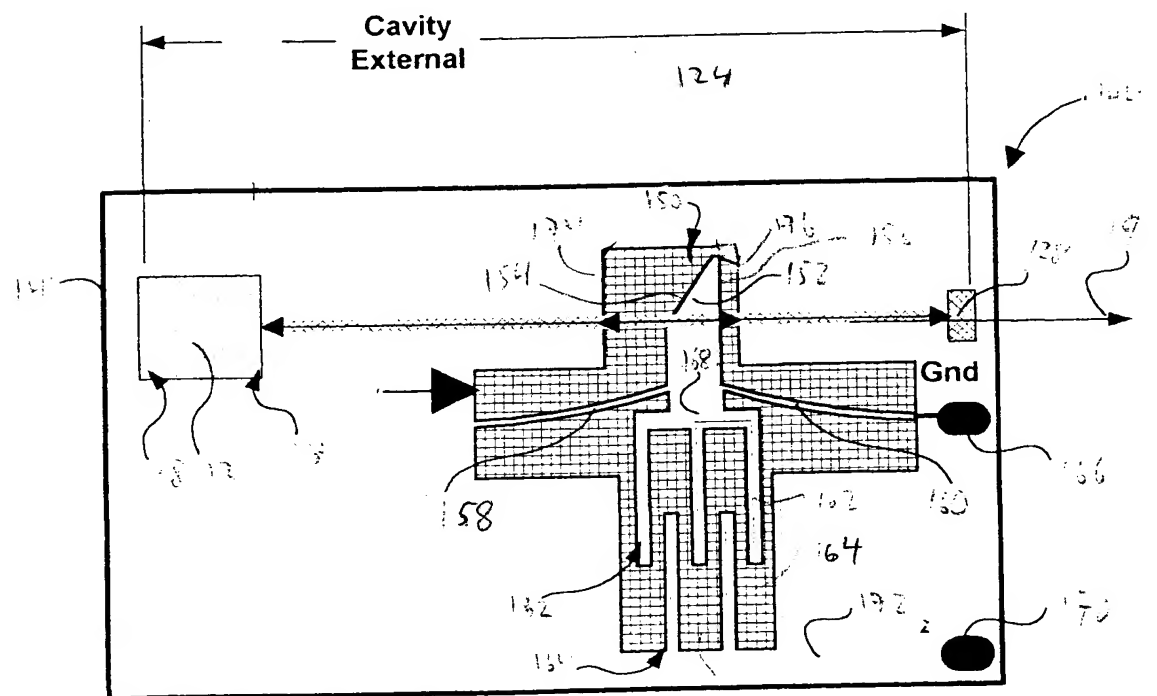


FIG. 2.



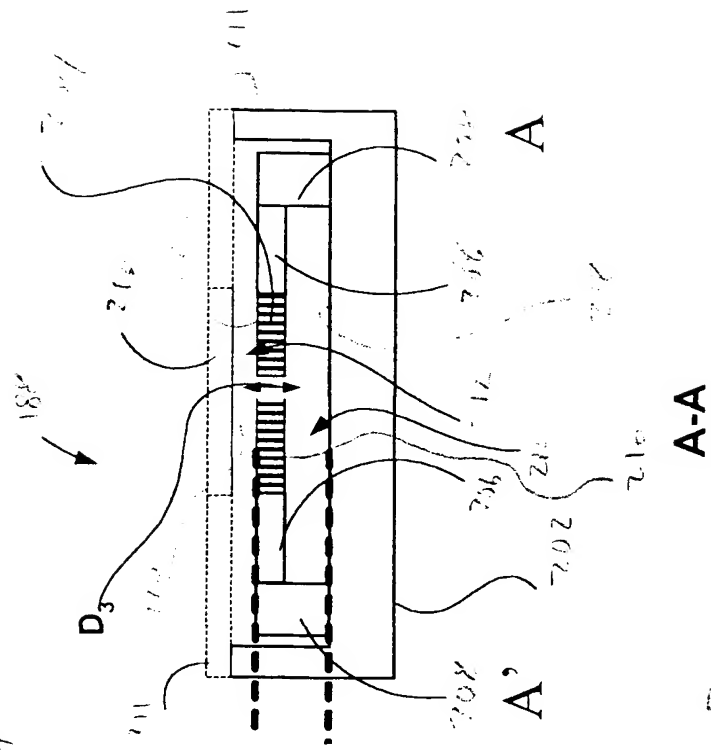
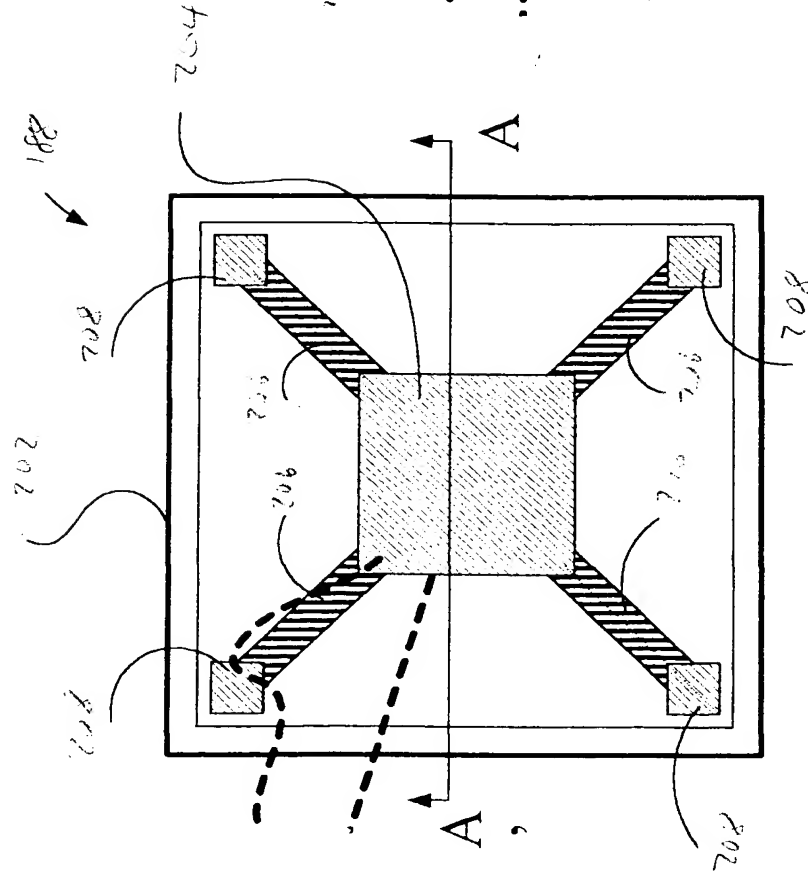


FIG. 14/1

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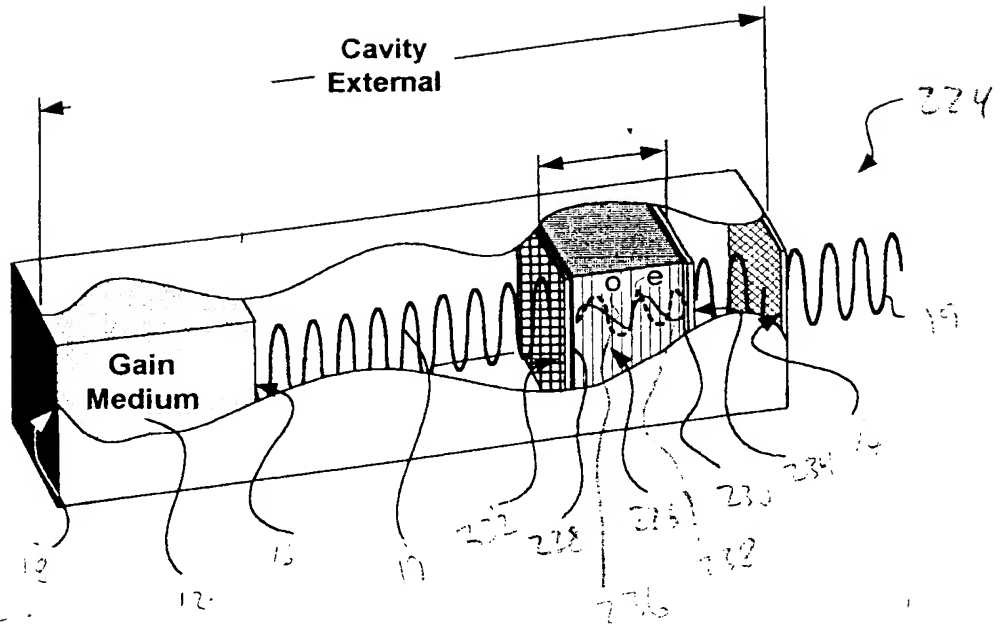
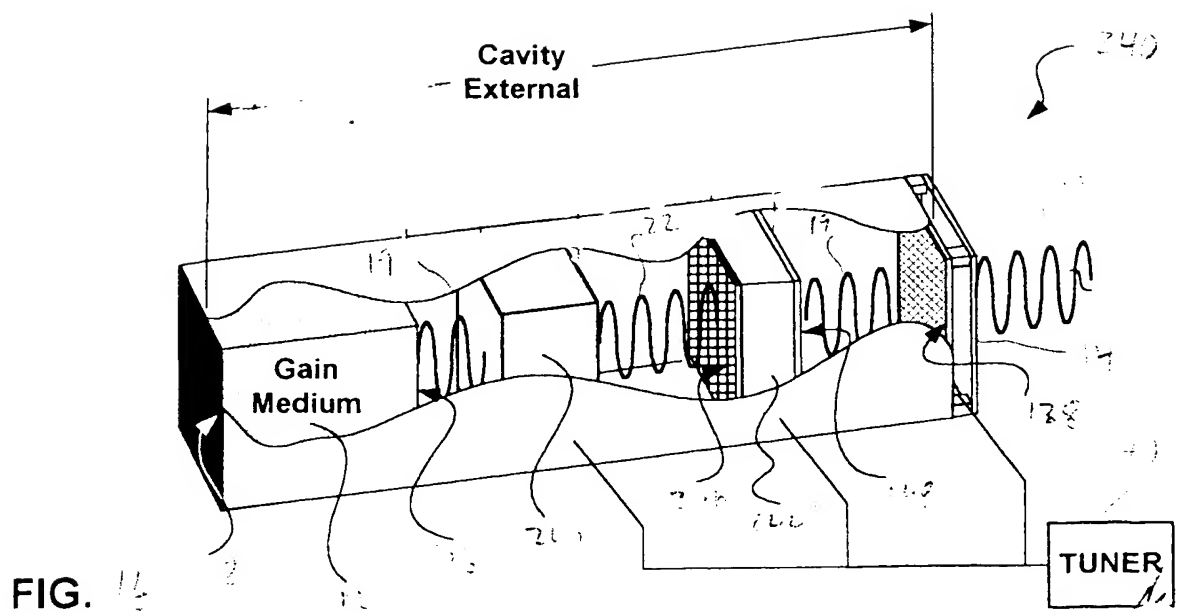


FIG. 15



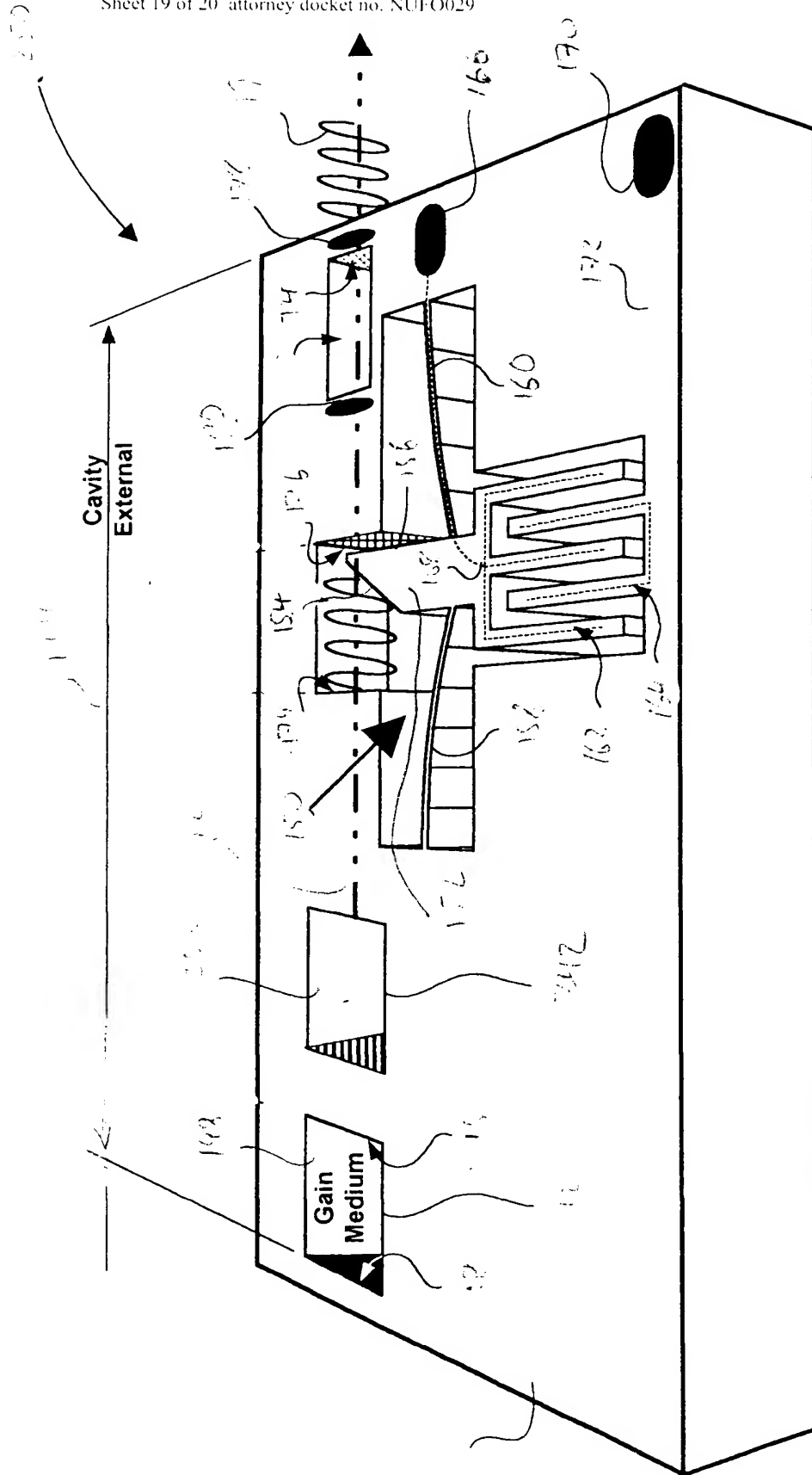


FIG. 1A

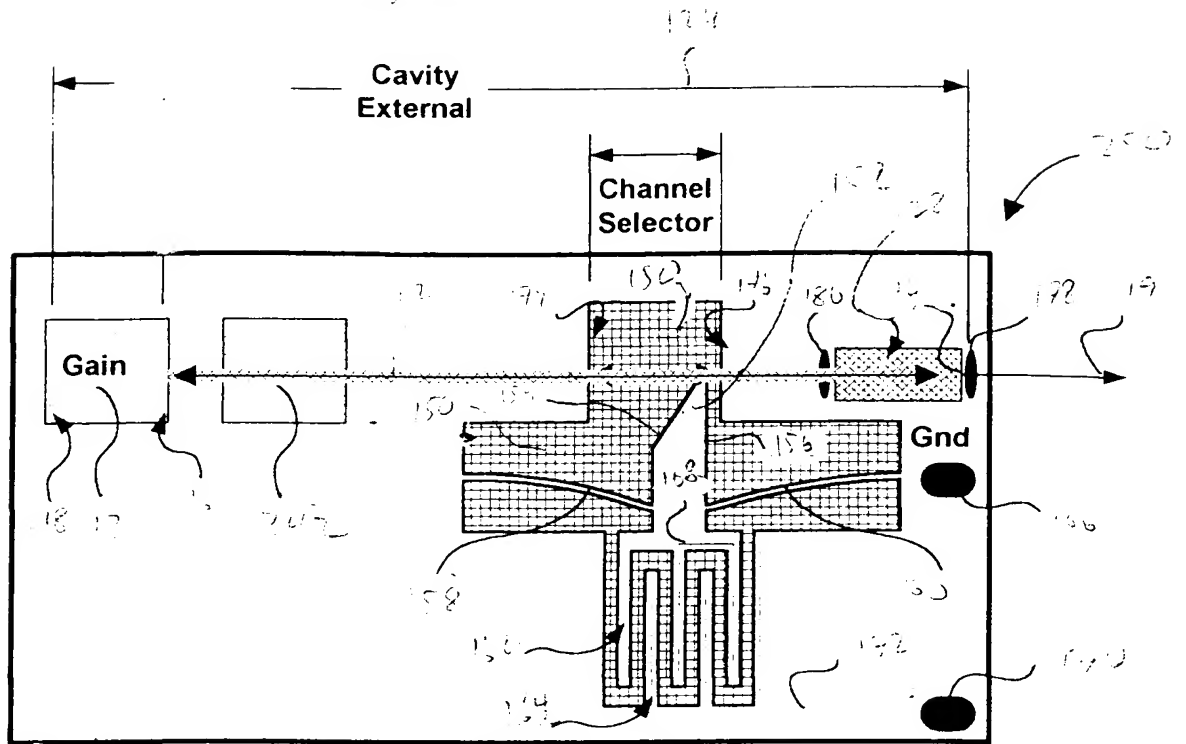


FIG. 1A

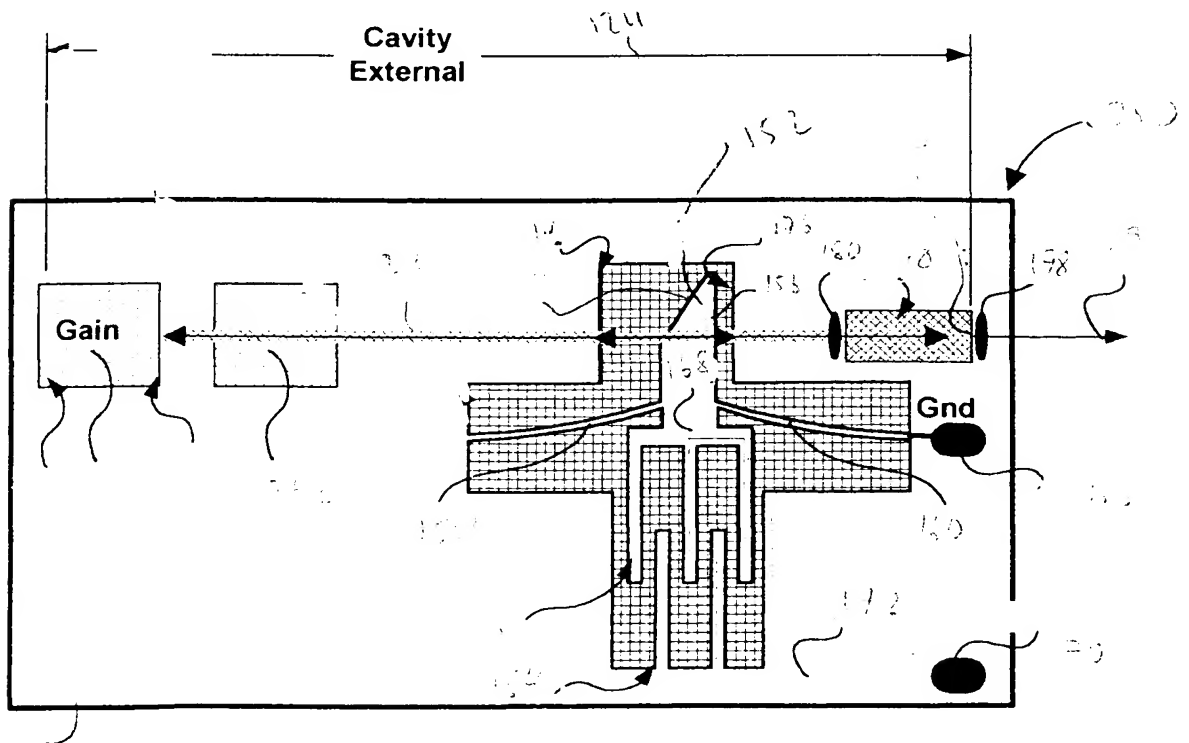


FIG. 1B